



 <p><b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)</p>	Docket Number (Optional) <b>C-531/470</b>	Application Number <b>10/034,005</b>
	Applicant(s) <b>Parris et al.</b>	
	Filing Date <b>12/28/01</b>	Group Art Unit <b>1755</b>

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA	4,289,678 A	09/15/81	Calder et al.	260	33.6 UA	10/16/79
	AB	4,460,732 A	07/17/84	Buscall et al.	524	460	06/17/83
	AC	4,597,794 A	07/01/86	Ohta et al.	106	20	07/03/84
	AD	5,415,964 A	05/16/95	Hayashi et al.	430	106	02/15/64
	AE	5,580,933 A	12/03/96	Verge et al.	525	301	06/07/95
	AF	5,869,564 A	02/09/99	Beach et al.	524	547	12/21/94
	AG	6,489,382 B1	12/03/02	Giesecke et al.	524	89	05/15/00

**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
	BA	EP 0 796 876 A1	09/24/97	WIPO	CO8F	212/08		
	BB	JP 2103274 A	04/16/90	Japan (Abstract)	C09D	11/00		
	BC	JP 7053612 A	02/28/95	Japan (Abstract)	C08F	002/44		
	BD	JP 7181715 A	07/21/95	Japan (Abstract)	G03G	009/08		
	BE	JP 8143804 A	06/04/96	Japan (Abstract)	C09D	011/00		

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER	DATE CONSIDERED
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**EXAMINER:** Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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